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## 3D printed electronics with nanomaterials

Marcin Słoma 

A large variety of printing, deposition and writing techniques have been incorporated to fabricate electronic devices in the last decades. This approach, printed electronics, has gained great interest in research and practical applications and is successfully fuelling the growth in materials science and technology. On the other hand, a new player is emerging, additive manufacturing, called 3D printing, introducing a new capability to create geometrically complex constructs with low cost and minimal material waste. Having such tremendous technology in our hands, it was just a matter of time to combine advances of printed electronics technology for the fabrication of unique 3D structural electronics. Nanomaterial patterning with additive manufacturing techniques can enable harnessing their nanoscale properties and the fabrication of active structures with unique electrical, mechanical, optical, thermal, magnetic and biological properties. In this paper, we will briefly review the properties of selected nanomaterials suitable for electronic applications and look closer at the current achievements in the synergistic integration of nanomaterials with additive manufacturing technologies to fabricate 3D printed structural electronics. The focus is fixed strictly on techniques allowing as much as possible fabrication of spatial 3D objects, or at least conformal ones on 3D printed substrates, while only selected techniques are adaptable for 3D printing of electronics. Advances in the fabrication of conductive paths and circuits, passive components, antennas, active and photonic components, energy devices, microelectromechanical systems and sensors are presented. Finally, perspectives for development with new nanomaterials, multimaterial and hybrid techniques, bioelectronics, integration with discrete components and 4D-printing are briefly discussed.

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Micro- and Nanotechnology Division, Institute of Metrology and Biomedical Engineering, Faculty of Mechatronics, Warsaw University of Technology, 8 Sw. A Boboli St., 02-525 Warsaw, Poland. E-mail: marcin.sloma@pw.edu.pl



Marcin Słoma

*Marcin Słoma is an Associate Professor at the Faculty of Mechatronics, the Warsaw University of Technology, Poland, and the head of the <sup>3</sup>WELES group developing functional heterophase materials for structural electronics. His PhD (received in 2011) was focused on the application of carbon nanotubes for printed electronics, and his DSc (received in 2018) was focused on the broader applications of carbon*

*nanomaterials for electronics technology. His research interests include additive manufacturing techniques and materials for printed and structural electronics, nanomaterials and nanocomposites, and energy harvesting devices.*

## 1 Introduction

Additive manufacturing technology, also called 3D printing, is of great interest for electronics applications. This technological advancement is additionally boosted by the use of nanomaterials and their superior properties. There are numerous 3D printing techniques, such as binder jetting, materials extrusion, materials jetting, powder bed fusion, sheet lamination, photopolymerisation and directed energy deposition, with new ones emerging each year.<sup>1</sup> It was just a matter of time to achieve additive manufacturing for fabricating 3D elements and circuits in electronics technology. This is a direct development from printed electronics technology, and these two branches of production are assimilating closer and closer together. 2D and 3D printed electronic devices allow enhanced portability, foldability, mechanical durability and integration, with growing interest visible in the number of publications on this topic in the last decade.<sup>2–7</sup> To fabricate 3D printed electronic devices and circuits with specific performance and applications, the selection of functional materials is of great importance, especially for conductive paths and circuits, dielectrics, semiconductors or magnetic and photonic elements and devices. This selection must go hand in hand with the adaptation of additive techniques, susceptible to the



While we already have an impressive collection of applications based on 2D printed electronics, including the application of nanomaterials, summarised in many collections, here the current achievements in 3D printed structural electronics with nanomaterials are summarised – we are going one dimension further. In this review, we will describe key additive technologies that are used or potentially can be integrated with nanomaterials to create functional electronic and mechatronic devices. Here, the focus is set on the selected nanomaterials used in 3D printed electronics: metal nanopowders and nanowires, graphene, carbon nanotubes and other materials such as dielectric, magnetic and semiconductor nanoparticles. We will describe the basic properties of selected nanomaterials and the formation of conductive and functional patterns using various additive techniques, with a brief description of their applications in various electronic devices. Finally, the prospects for future research on 3D printed electronics with nanomaterials are proposed in terms of materials selection, printing methods, or even 4D printing approach.

Printed electronics, in short, is an application of printing technologies to fabricate electronic devices using specially adapted functional inks and pastes. With a few decades of development, it has gained great interest in research and practical applications and is successfully fuelling the growth in materials science and technology. Printed electronics have various applications, from simple paths, electrodes or antennas requiring conductive layers,<sup>8–10</sup> to complex transistors and integrated circuits,<sup>11–14</sup> energy devices,<sup>15–20</sup> and wearables (see Fig. 1).<sup>21–24,421</sup> Some require patterning and some are based on full-area coating. Examples of the achievements of printed electronics are presented in Fig. 1.

Almost all electronic components require conductive electrodes based on highly conductive materials. Here the range of available materials is the broadest.<sup>4,25,26</sup> The mainly used conductive materials are metal nanoparticles (NPs) and nanowires (NWs) from Ag, Cu, Ni or Au, to name a few,<sup>5,27–34</sup> carbon nanotubes (CNTs),<sup>3,35–40</sup> graphene platelets (GNPs),<sup>41–46</sup> conductive polymers,<sup>47–49</sup> transparent conducting oxide nanoinks (TCOs),<sup>50–52</sup> semiconductor nanomaterials,<sup>53–57</sup> and more recently also reactive inks (nanomaterial-free) with metallic compounds and complexes as precursors, converted to bulk metal in the post-treatment process.<sup>58–61</sup> Optoelectronic devices such as displays, organic light emitting diodes (OLEDs), and solar cells additionally require transparent electrodes for a trade-off between transparency and conductivity.<sup>62–64</sup> Semiconductor inks in the form of nanomaterials dispersions or solutions of conjugated polymers are

used to fabricate transistors and optoelectronic devices,<sup>65,66</sup> and various active materials are needed for the production of sensors.<sup>67–70</sup> New frontiers are opening on the fabrication of all the above-mentioned applications with eco-friendly materials for disposable electronic devices,<sup>71–74</sup> and new fields of hybrid approaches are emerging, such as patchable<sup>75,76</sup> or ingestible bioelectronics.<sup>77,78</sup> The selection of materials is mainly determined by the required physical properties of the devices, such as conductivity, but an additional functionality is often required, such as optical transparency or mechanical stability to bending, twisting and stretching, which is especially important for flexible electronics. In most cases, the final functionality of the electronic product is related to both properties of the ink and the substrate, and the synergy of both. Besides the rigid substrates (glass and ceramics), the key players in printed electronics are elastic substrates in the form of polymer foils<sup>25,79,80</sup> or paper<sup>81–83</sup> and textiles.<sup>10,84,85</sup>

A large variety of printing, deposition and writing techniques have been incorporated to fabricate electronic devices in the last decades. While the term printed electronics often also covers coating techniques such as spin, spray, dip, slot die, blade and bar coating, we will focus here only on the printing techniques allowing for selective patterning of devices and circuits. This is especially important because selected 2D printing techniques are also used for the 3D printing of electronics. To briefly introduce to the reader some of the applications of the coating techniques, it is worth mentioning that they are often used for processing transparent electrodes or large-scale photovoltaics, and the coating processes can be easily scaled up and are adaptable to large-scale roll-to-roll production. In the group of the most popular printing techniques used in printed electronics applications, several are the key players, including screen printing (flatbed and rotary),<sup>20,86–89</sup> gravure and rotogravure,<sup>20,90–92</sup> flexographic,<sup>93,94</sup> and offset printing.<sup>95,96</sup> All techniques mentioned above are in the group of contact printing, which means that the tool (mask, matrix, stencil) is in direct contact with the substrate during the deposition process. These techniques also require the fabrication of patterned, indispensable masks, thus often introducing high setup costs and time. On the other hand, we have a series of non-contact techniques. This group is also highly exploited in the research and applications of printed electronics technology. Among the non-contact printing technologies, two techniques gained a lot of interest: ink-jet printing<sup>56,69,82,97,98</sup> and Aerosol Jet Printing (AJP).<sup>12,99–101</sup> The ink-jet technique can be additionally divided into Drop-On-Demand (DOD), continuous ink-jet printing and electrohydrodynamic jet printing, with the first being the most popular among the non-contact, maskless printing techniques. All these maskless techniques are often called digital printing, meaning they do not require additional mask fabrication, and the design can be directly printed on the Computer Numerically Controlled (CNC) setup. One of the serious drawbacks of the ink-jet technique is the use of low-viscosity inks to avoid nozzle clogging,<sup>102</sup> limited for AJP.<sup>99</sup>

Due to the nature of several contact printing techniques and the incorporation of masks or stencils for the selective





**Fig. 1** Printed electronics applications. (a) and (b) Fully screen-printed SWCNT TFT arrays on rigid and flexible substrates.<sup>13</sup> Reprinted with permission from American Chemical Society, copyright 2014. (c) Inkjet-printed paths using silver nanoparticle inks on cotton woven fabrics connected to a LED and a battery.<sup>10</sup> Reprinted with permission from American Chemical Society, copyright 2017. (d) A flexible lithium-ion battery turns on a blue LED under bending.<sup>19</sup> Reprinted with permission from American Chemical Society, copyright 2012. (e) Screen printed planar thermoelectric generator on the Kapton substrate.<sup>15</sup> Reprinted with permission from Elsevier, copyright 2016. (f) Rolls of gravure-printed inverted OPV modules.<sup>20</sup> (g) Fully screen-printed, multicolour electroluminescent displays in the bent and twisted states.<sup>24</sup> Reprinted with permission from American Chemical Society, copyright 2020. (h) Printed e-label with the antenna-diode-display circuit.<sup>14</sup> Reprinted from the National Academy of Sciences, copyright 2016. (i) Transfer printed seven-segment PLED displays as an example of epidermal electronics.<sup>421</sup> Reprinted from the American Association for the Advancement of Science under a Creative Commons Attribution NonCommercial License 4.0, copyright 2016.

deposition of inks, their use is severely limited or even impossible in 3D additive manufacturing. At the same time, maskless non-contact printing techniques (ink-jet and AJP) have attracted significant attention in the area of additive manufacturing. Moreover, the translation from 2D to 3D printing with these digital techniques is very efficient. Therefore the two above-mentioned maskless, non-contact jet techniques will be covered in detail in further sections of this review.

### 3 Additive manufacturing – the enabler

Additive manufacturing is called by many names, but the most popular term is 3D printing. With the definition from the American Society for Testing and Materials (ASTM), it is 'a process of joining materials to make objects from 3D model data, usually layer upon layer'.<sup>103</sup> In other words, it is a computer-controlled fabrication of a three-dimensional object, with

the material being sequentially deposited layer-by-layer along the Z-axis, from the computer-generated slicing code of the object.<sup>104</sup> There are two basic 3D printing technologies based on the selective treatment of material: deposition from a nozzle (polymers, inks) and batch solidification (liquids, powders), with minor modifications (*i.e.* binder jetting of ink onto the powder). Detailed subdivision into several categories differing mainly by the method of layer deposition and fixation as well as by the used material is described in further sections (Fig. 2). A lot of similarities can be observed with the previously mentioned digital printing techniques while 3D printed structures are first digitally constructed as 3D models with computer-aided design (CAD) software, and later this geometry is interpreted and synthesized into a machine code which the 3D printer uses to produce bulk solid objects. Therefore no additional tools are fabricated, such as press stamps or injection moulds. Thanks to that, 3D printing profits from the capability to create geometrically complex constructs with low cost and minimal material waste. Initially







Fig. 2 Selected additive manufacturing processes most suitable for 3D printed electronic applications.

developed as a rapid prototyping technique, 3D printing has become increasingly accessible with the advent of low-cost desktop 3D printers,<sup>105</sup> gained more powerful traction with the development of novel printing technologies,<sup>106–110</sup> and now stepping into professional applications such as the aerospace and automotive industries.<sup>111–116</sup> While primarily developed for mechanical and construction element fabrication, 3D printing also spread beyond industry, especially in the field of medicine, addressing clinical needs, creating personalized implants and prostheses,<sup>117–121</sup> regenerative scaffolds,<sup>122–124</sup> drugs and drug delivery devices,<sup>78,125–127</sup> or even enabling printing of living cells, leading to the creation of biological tissues and organs.<sup>128–131</sup>

Having such tremendous technology in our hands, it was just a matter of time to implement additive manufacturing techniques for fabricating elements and circuits in electronics technology through combining the advances of printed electronics technology. As such, the enabling possibility of fabricating 3D structural electronics emerged. But only selected techniques are adaptable for printing electronics, and here, in this section, we will look closer at several of the most popular 3D printing techniques concerning their possible applications in 3D printed electronics fabrication. At the end of this section, other 3D printing additive techniques that have not yet gained much attention for producing electronic devices are also briefly mentioned.

The general concept of additively manufactured structural electronics is based on the fabrication of 3D structures with

multilayered circuitry by selectively applying conductive and insulating materials to each layer, connecting them with inter-layer conductive paths and additional mounting of non-printable discrete electronic components or small subsystems like integrated circuits (Fig. 3).<sup>132–134</sup> Fabrication of paths and basic elements can be achieved *via* conformal printing without 3D printers, but selective printing techniques allow fabricating truly structural bulk circuitry embedded inside casings or construction elements. In the literature, we can find many successful attempts to fabricate various 3D printed electronic components and devices with different architectures to demonstrate the potential of additive manufacturing, yet readers need to be advised that the “3D printing” term is consequently overused most of the time for planar printing techniques. Most often, “additive manufacturing” is used for all additive approaches for fabricating electronic components. This is because printed electronics, involving multiple passes and building planar devices layer-by-layer, is, in fact, also an additive approach, and this is the source of misunderstanding. In this review, the focus is on printing techniques fabricating as much as possible spatial 3D objects (according to the mentioned ASTM definition), with embedded components, vertical interconnects, bulk load-bearings *etc.*, or at least conformal ones on 3D substrates (thin-film ink-based techniques). Wherever possible, examples of impressive achievements of 2D printed electronics are presented, with great potential for implementation in the 3D printing of electronics (in analogy to ink-jet utilising the same concept as PolyJet).

### 3.1 Fused deposition modeling – FDM

One of the most popular and widespread additive techniques is Fused Deposition Modelling (FDM, a brand name of Stratasys), also called Fused Filament Fabrication or Filament Freeform Fabrication (FFF). It is in a group of selective deposition of a liquid/melted material. The principle of this technique is based on extruding a thermally molten or semisolid material through a nozzle, followed by its solidification through cooling, to form a single layer, and the process repeats for the second layer.<sup>135–137</sup> During the FDM process, the thermoplastic filament is fed from a spool and melted by the heated extruder head to decrease the viscosity. The melted filament is mechanically extruded through the tip of the nozzle by pressure induced from feeder rollers transporting



Fig. 3 Opportunities for the adaptation of structural electronic circuits with embedded conductive tracks and components. Examples (a)<sup>132</sup> and (b)<sup>133</sup> reprinted from Elsevier B.V., under Attribution-NonCommercial-NoDerivs 3.0 Unported license, copyright 2014. (c)<sup>134</sup> Reprinted from MDPI, Basel, Switzerland, under Creative Commons Attribution 4.0 license, copyright 2022.





the filament. The heated nozzle is positioned to perform planar movement according to the preset profile trajectory. The extruded filament is cooled shortly after deposition, progressively adhering to the build plate or previously cured layers. This process is defined by the resolution categories: Z resolution, XY resolution, and the minimum feature size.<sup>138</sup> Resolution on the Z axis corresponds to the minimum layer height. In techniques such as FDM (or later described optical techniques), this value is correlated with the resolution of the motors driving the build plate or printer nozzle. The same applies to the XY resolution corresponding to the minimum horizontal movement of the build plate, nozzle or the optical imaging system. The XY resolution determines the minimum

feature size, which can be defined as the smallest horizontal feature allowable to be printed. This is also related to the feature size determined in the FDM process by the diameter of the nozzle.<sup>108</sup> In standard FDM equipment, the minimum feature size is in the range of 100  $\mu\text{m}$ , and the printing speed defined by the length of the filament extruded *via* the nozzle is in the range of 1–10  $\text{m min}^{-1}$ .<sup>139–141</sup> Fig. 4a shows the working principle of the FDM technique.

The leading materials for the FDM technique are various thermoplastic polymers that can be thermally melted and extruded.<sup>141,142</sup> Such a thermoplastic filament from polymers or composites has to be prepared beforehand using other extrusion processes in the form of filaments, with a standard



**Fig. 4** Schematic illustration of selected 3D printing techniques: (a) extrusion-based methods such as fused deposition modelling (FDM) and (b) direct ink writing (DIW), (c) inkjet printing and Multi-Jet techniques, (d) aerosol jet printing (AJP), (e) UV resin-based method stereolithography (SLA) and (f) powder-based methods such as selective laser sintering (SLS). Figures (a–c, e, f),<sup>120</sup> copyright 2016, and (d),<sup>182</sup> copyright 2013, reprinted and adapted with permission from American Chemical Society. (g) Knee inserts from a Co–Cr–Mo alloy fabricated with the EBM technique.<sup>121</sup> Reprinted with permission from Elsevier, copyright 2017. (h) Full-size working excavator equipped with a 3D printed arm containing incorporated hydraulic lines fabricated with the WAAM/mBAAm technique.<sup>206</sup> Reprinted with permission from Elsevier, copyright 2019. (i) Functional 3D printed loudspeaker with combined FDM and DIW techniques.<sup>223</sup> Author Jason Koski, reprinted with permission from Cornell University Photography. (j) 3D printed capacitive 'smart' vessel.<sup>225</sup> Reprinted from PLOS, under Creative Commons Attribution License, copyright 2012. (k) Human interface device (HID) FDM printed from a high-conductivity copper-filled composite.<sup>226</sup> Reprinted from Springer Nature, under Creative Commons Attribution 4.0 International License, copyright 2018. (l) 3D printed "smart cap" for rapid detection of liquid food quality featuring wireless readout.<sup>228</sup> Reprinted from Springer Nature, under Creative Commons Attribution 4.0 International License, copyright 2015. (m) Fabrication of the 3D 555 timer circuit with SLA and DIW techniques.<sup>230</sup> Reprinted with permission from Emerald Publishing Limited, all rights reserved.



diameter according to the printer's nozzle. Optionally FDM printers can be equipped with a hopper and a screw extruder, as in the injection moulding process, to directly extrude thermally melted polymer pellets *via* a heated nozzle.<sup>143,144</sup> Polymers required for FDM processing are usually from the most popular group of acrylonitrile butadiene styrene copolymers (ABS), polylactic acid (PLA), polycarbonate (PC), polyurethanes (PU), polyphenylsulfone, poly(ether ether ketone), and poly(ether imide).<sup>141,145</sup>

The main advantages related to the use of the FDM technique, to name a few, are the relative simplicity and low cost of the equipment (printers can cost as little as a few hundred dollars), widely available polymer filaments and a relatively high print speed.<sup>105,141,146</sup> The main disadvantages are related to the fabrication of supporting structures required for free-standing models (in contrast to a powder bed system), relatively low resolution in terms of precise electronic devices and possible nozzle clogging for viscous composite filaments. Nevertheless, the most significant advantage in the scope of electronics printing is easy integration to achieve multi-material printing,<sup>135,147</sup> which could be easily implemented by simply adding as many printing nozzles as the number of materials needed to be processed.

### 3.2 Direct ink writing – DIW

Direct ink writing (DIW) is a very similar technique to the above-mentioned FDM printing, except that the printing material used here is in the form of a viscous functional ink instead of a filament, and there is no thermal melting of the material. The functional ink stored in the syringe container is extruded using pressure from a needle-like nozzle and deposited on a substrate or a previous layer.<sup>148</sup> Pressure is generated on the piston *via* a pneumatic gas pump or motor-driven screw. The materials used here are in the form of low-viscosity inks flowing easily through the nozzle or shear-thinning pastes requiring a much larger driving force. When using low-viscosity inks, a curing system is used to cure the extruded filament instantly, allowing the retention of its 3D structure. Such post-processing steps used to solidify the extruded ink are related to photopolymerization or thermal curing.<sup>108,148</sup> A modification of this process uses an additional shear thinning fluid, or a high viscosity gel, as a supporting matrix in a reservoir, with a nozzle injecting a low viscosity filler material into this supporting matrix.<sup>149</sup> In standard DIW equipment, the minimum feature size is in the range of 1–500  $\mu\text{m}$ , heavily ink dependent,<sup>148,150,151</sup> and the printing speed defined by the volume of the extruded paste *via* the nozzle is in the range of 100–1000  $\text{mL h}^{-1}$ .<sup>148,152,153</sup> Other process parameters related to the XY and Z axis resolution remain similar to the FDM technique due to many similarities in the equipment construction. Fig. 4b shows the working principle of the DIW technique.

Direct ink writing is a highly flexible technique regarding the used material. Inks can be formulated from polymeric and colloidal suspensions or even adapted from printing techniques such as screen-printing.<sup>154</sup> The range of viscosity for

the materials is large, from liquid to paste, usually in the range of  $10^2$ – $10^8$  [cP].<sup>155–157</sup> Due to this, various suspensions, shear-thinning fluids, gels, foams, composite mixtures, and even biological cells can be printed.<sup>158–162</sup>

DIW offers many benefits, including printing at room temperature, the versatility of materials, including biological inks, and the easy fabrication of free-standing structures.<sup>163,164</sup> Some disadvantages are related to complex ink formulation for small feature sizes, and using various binders can result in inferior electrical properties.<sup>108</sup> Similarly to FDM, DIW offers a distinct advantage for 3D printed electronics as the implementation can be done easily with multiple nozzles and multi ink reservoirs, which allows integrating multiple functionalities in a 3D printing format.<sup>165,166</sup>

### 3.3 Direct ink jetting

A different approach for the selective deposition of a material is direct ink jetting, with several names used, such as ink-jet for the printing industry and printed electronics or Poly-Jet, Multi-Jet used in additive manufacturing for the description of 3D printing. As mentioned previously in the Printed electronics – the origin section, the most often used technique is Drop-On-Demand (DOD), with thermal or piezoelectric actuators propelling low-viscosity inks and ejecting droplets from micrometre-sized nozzles onto a build plate.<sup>167–169</sup> Thermal printers heat the ink in microseconds, thermally expanding the ink volume (forming a bubble), and force a drop of ink through the nozzle, while piezoelectric printers apply voltage to a piezoelectric membrane attached to a glass tube, changing the pressure inside the ink chamber propelling a droplet through the nozzle. Deposited 2D patterns are instantly photo-cured under UV irradiation by the lamp attached next to the printhead.<sup>170,171</sup> In low-viscosity ink techniques such as Multi-Jet, the droplet thickness determines the Z resolution. Ink droplets as small as 2–12 pL can be deposited with this method, resulting in a thin layer of a few micrometres even down to the sub-micron scale.<sup>171,172</sup> Similarly to the FDM and DIW techniques, XY minimal resolution corresponds to the horizontal movement of the build plate or printhead, and it is in the range of 5–100  $\mu\text{m}$ , additionally determined by a footprint of the deposited ink droplet.<sup>108,170,173</sup> The printing speed defined by the volume of the deposited ink is in the range of 100–1000  $\text{mL h}^{-1}$  for multi-head multi-nozzle systems.<sup>170</sup> Fig. 4c demonstrates the working principle of the Multi-Jet 3D printing technique.

Ink-jet techniques require very low viscosity inks for efficient printing and the ink has to be precisely formulated to prevent nozzle clogging.<sup>102</sup> Usually there is very limited range of viscosity values that can be used, most often  $<0.25$  Pa s.<sup>170,174,175</sup> Similarly to DIW and further discussed AJP, the deposition of ink without high temperatures allows for the deposition of a wide range of thermally fragile and living biological materials.<sup>130,176</sup>

The main advantages of ink-jet based techniques are related to the use of various substrates, limited waste production, easy application of a low-viscosity solution, and most







to FDM or DIW techniques, related to the resolution of the motors driving the height of the build plate. Here, the XY minimum feature size is determined by the spot size of the laser for SLA (10–200  $\mu\text{m}$ )<sup>187</sup> and pixel size for DLP-based techniques (range of micrometres).<sup>191,192</sup> The fabrication speed is among the fastest in 3D printing, reaching  $10^6 \text{ mm}^3 \text{ h}^{-1}$  for SLA, and even ten times faster for DLP and CLIP techniques.<sup>190,191</sup> Fig. 4e demonstrates the SLA printing technique.

Materials selection for SLA is limited, as they all need to be photocurable resins. This is very similar to the previously mentioned Multi-Jet technique. Within this group, we can find a lot of different materials with various physical properties, especially with different mechanical properties. Yet, the fabrication of conductive or bioactive materials is difficult or sometimes impossible due to the use of crosslinkers and catalysts that are UV activated.<sup>193</sup>

The advantages of VAT polymerisation techniques relate to a very smooth surface in comparison with FDM, higher overall resolution, and high throughput, all these with relatively low-cost equipment.<sup>190,194</sup> Unfortunately, for SLA and similar techniques, we face the synergy of the most impactful disadvantages of additive manufacturing: limitation to a single material printing and need for photocurable resins, both creating problems in the fabrication of electrically conductive components. Some of the rare multi-material VAT solutions will be listed in the Perspectives at the end of this review.

### 3.6 Powder bed techniques

Besides the most popular deposition and polymerisation techniques, it is also necessary to mention a vast group of powder-based techniques. Although their use in 3D printed electronics fabrication is very limited, they play a key role in the automotive and aerospace industries or mass production of implants for biomedical applications. Powder-based technologies utilize the material in a solid state (powder) from a vast range of functional materials (plastics, ceramics, and metals). These techniques share many similarities with the previously mentioned VAT polymerisation techniques, while here the resin is substituted with powder, and different techniques for selective solidification of powder are used. For all these techniques, the basic principle is that the pattern of each deposited layer of powder is converted into a continuous solid. This conversion can be achieved by Selective Laser Sintering (SLS), Selective Laser Melting (SLM), Direct Metal Laser Sintering (DMLS), Electron Beam Melting (EBM), and by ink-jetting a binder on the layer of powder (Binder-Jet) that might be additionally sintered with an IR lamp in Multi-Jet Fusion techniques (MJF)<sup>195–199</sup> or post-processed in furnaces for sintering ink-jet binding metal powders like Metal-Jet.<sup>200,201</sup> As an example of powder techniques, in SLS, instead of a photocurable resin, a bed of polymer, ceramic, or metal powder is sintered (or melted for SLM) with a laser,<sup>198,199</sup> after that the bed retracts, a fresh layer of powder is rolled onto the top of the part, and the process repeats. The powder bed is usually able to support the construct, and hence, no additional supporting structures

are needed as required for FDM, SLA or Multi-Jet techniques. In this technique, resolution limitations are related to the size of the particles to be sintered (or bound) and the spot of the energy beam or the ink drop, but can still achieve a feature size of approximately 50–100  $\mu\text{m}$ .<sup>198,199</sup> Generally, XY and Z resolution is also drive-related as for the FDM or SLA techniques (movement of the build plate, nozzles or optics). Fig. 4f shows the working principles of the SLS technique.

One of the biggest advantages of this group of techniques is fairly large availability of materials. Occasionally some techniques need no support for printed structures (SLS, MJF, and Binder-Jet), no thermal stress for the Binder-Jet technique, and mechanical properties comparable to milling or moulding (SLM, DMLS, and EBM) (Fig. 4g). At the same time, some disadvantages are related to the high porosity of the final parts, and for high-temperature laser or electron beam processes, thermal stresses have to be considered as they can cause distortion to the printed part.<sup>195,199</sup> As for the VAT polymerisation techniques, the drawback for electronics applications is in the “one powder at a time” process, although bulk conductive metal parts are also possible to fabricate. And the same as for SLA, some attempts for multi-material fabrication will be presented in the Perspectives section.

### 3.7 Other techniques

A brief glimpse of other emerging additive techniques covers concrete extrusion for house building,<sup>202,203</sup> Wire-Arc Additive Manufacturing (WAAM) incorporating wire-arc welding and a 6-axis robotic manipulator,<sup>204,205</sup> Big-Area Additive Manufacturing (BAAM) being a sort of very large-scale FDM,<sup>206–208</sup> Direct Energy Deposition (DED) involving the melting of metal powder with a high-powered laser beam,<sup>209</sup> or liquid and molten metal ink-jet, FDM and DIW techniques.<sup>210–214</sup> An example of a full scale excavator arm fabricated with the WAAM/BAAM technique is presented in Fig. 4h.

### 3.8 3D printed structural electronics

Various 3D printing technologies have already been explored with polymer composites, metal and carbon nanomaterials, powders or other materials owing to the increasing research interest in the 3D printing of electronics. There have been a number of books, reviews and foresight papers published in the last decade on the applications of 3D printing of electronics.<sup>2,4,215–221</sup> From the most promising and revolutionary concepts introduced in the literature, there needs to be mentioned a fully 3D printed loudspeaker with FDM and DIW techniques,<sup>222,223</sup> followed by one of the most complete 3D electronic printers introduced to the market, combining FDM and DIW with low-viscosity, reactivity, and low-temperature cured silver inks exhibiting resistivity close to bulk silver.<sup>224</sup> FDM printed composites were used for the fabrication of piezoresistive and capacitive sensors for smart gloves, smart vessels and tactile pads,<sup>225,226</sup> large-scale composite magnets,<sup>207</sup> and polymer composites highly-loaded with dielectric ceramic powders.<sup>227</sup> By the combination of SLA and



DIW techniques, a portfolio of 3D printed resistors, inductors and capacitors with a wireless “smart cap” for a milk package was prepared,<sup>228</sup> including a functional electrical circuit with a 555 timer, an electronic gaming die, and a set of sensors embedded in a helmet,<sup>229–231</sup> and a university-based startup prepared a low orbit satellite.<sup>232</sup> Also, SLS techniques are used for the fabrication of electrodes<sup>233</sup> and antennas<sup>234,235</sup> from metal powders. Selected applications of additive manufacturing for the fabrication of functional components in the mentioned domains are presented in Fig. 4.

## 4 3D printed nanomaterials – the game-changer

In previous sections, we saw how additive manufacturing could overcome the limitations of conventional subtractive manufacturing methods (*i.e.* machining) or formative methods (*i.e.* forging and casting) to create complex geometries and multifunctional, multi-material structures. These new perspectives provided by additive manufacturing to integrate various materials into multifunctional constructs enable the creation of unique electronic devices. Nanomaterial patterning with additive manufacturing techniques can be the enabler for harnessing their nanoscale properties and effects and the fabrication of active structures with electrical, mechanical, optical, thermal, magnetic and biological properties. In this section, we will briefly review the properties of selected nanomaterials suitable for electronic applications and look closer at the current achievements in the synergistic integration of nanomaterials with additive manufacturing technologies to fabricate 3D printed structural electronics.

### 4.1 Nanomaterials

Nanomaterials are materials with one spatial dimension between 1 and 100 nm. Such small dimensions promote a range of unique properties related to the size and morphology of nanomaterials not explored previously with bulk materials, even on the microscale.<sup>236–238</sup> The easiest one to explain is the surface area, which is substantially high for nanomaterials compared to their bulk counterparts, and it is unrelated to the building atoms of nanomaterials. Furthermore, a material with dimensions on this scale and significant values of the surface-to-volume ratio exhibits modified physical and chemical properties. The weakly bound surface atoms at the surface of the nanoparticles foster melting-point depression due to their reduced cohesive energy (300–400 °C instead of 1064 °C for Au),<sup>239</sup> increase their chemical reactivity, and compared to the bulk material structure, the mechanical and electrical properties of nanomaterials are improved by increases of crystal perfection or reductions of defects.<sup>240,241</sup> Such size-dependent effects arising from the nanoscale are sometimes directly perceived in our macro world, like Au or Ag nanoparticle solutions that appear purple or red, instead of yellow-orange or soft-white shiny colours of the bulk materials, respectively. And such effects can be tuned *via* the size of the nanomaterial par-

ticle and not their chemical structure.<sup>190,237</sup> The same applies to the luminescence emission from quantum dots (semiconducting nanoparticles) with different diameters (1–10 nm) affecting the emission wavelength that is exploited to create LEDs and display devices with exceptionally high-colour purity.<sup>242,243</sup> A great number of research studies are also conducted towards exploiting nanomaterials’ antiviral, antibacterial, and antifungal properties and their capacity to deal with pathogen-related diseases.<sup>244,245</sup>

For the fabrication of 3D printed electronic devices, we have to have specific electrical, dielectric, magnetic, semiconductive and other properties. The simplest approach to harness the potential of nanomaterials is the fabrication of low-temperature sintered conductive nanomaterial traces enabling the electrical conductivity almost at the same level as the bulk material.<sup>246</sup> For this, the most utilised material is silver nanoparticles (AgNPs).<sup>247</sup> However, due to their high cost, a lot of work is directed to replacing them (and other noble metals, such as gold or platinum) with less expensive counterparts, such as copper, aluminium or nickel. Some major challenges exist in this field, while their oxidation under ambient conditions is considerably high, an inert atmosphere would be required during the fabrication process.<sup>248–250</sup> To eliminate this obstacle, attempts are made to use additional reducing agents or coat the nanoparticles with other metals (*i.e.* Cu@Ag).<sup>58,60,251</sup> While a highly developed surface promotes fast oxidation of nanoparticles, at the same time the increased surface area of metal and carbon nanomaterials allows creating novel devices, such as supercapacitors.<sup>252</sup> At the nanoscale level, a non-magnetic element can become magnetic.<sup>253</sup> Such small sizes also promote the quantum confinement effect as the motion of their electrons are confined to a higher degree than their corresponding bulk counterpart, creating plasmon resonance, enabling the creation of highly sensitive biosensors and improved solar cell efficiency.<sup>254–256</sup> Other confinement effects provide metal-like properties in non-conductive materials. For example, boron in bulk form is not considered a metal, while a borophene (2D sheet of boron atoms) is an excellent conductor,<sup>257</sup> similarly titanium aluminium carbide (Ti<sub>3</sub>AlC<sub>2</sub>) ceramics in a 2D-layered structure exhibit metal-like electrical conductivity,<sup>258</sup> what most of all applies to the celebrity of nanomaterials, graphene.<sup>259–261</sup> The intriguing feature of nanomaterials is also the influence of the crystallographic chirality along the 2D sheet. This is the most known electronic feature of the graphene sheet, being the foundation of carbon nanotubes (CNTs). Depending on the chirality angle (direction of electron transport in the hexagonal graphene sheet), carbon nanotubes can be almost metal-like conductors or semiconductors<sup>259,262</sup> without the change in their chemical structure, remaining purely carbon-based.

The above-mentioned features have made nanoscale materials valuable assets for a wide range of applications, promising exceptional boosting of the performances of various electronic devices. Here comes the printed electronics technology and subsequently 3D printed structural electronics. But both these approaches require the preparation of nano-



materials (usually in the form of nanopowders) for the efficient deposition and fabrication of complex systems. Here, composites arise as the most efficient use of nanomaterials for the fabrication of bulk structures with enhanced physical properties. However, the complexity of composites and ink preparation deserves separate review papers, and readers are advised to explore other sources on this topic.<sup>263–266</sup> The challenge is to do it efficiently and with the most optimised results with respect to the expected properties.

## 4.2 3D printing with nanomaterials for structural electronics

In the literature, we find a great number of review papers dealing with printed and 3D electronics with nanomaterials.<sup>4,181,267–271</sup> Most papers presenting successful attempts to fabricate various 3D printed electronic components and devices are focused on the conductive paths, passive components, circuitry, antennas, and electrodes. Less information is presented regarding more problematic active components and photonic and energy devices. A large part of experiments is devoted to sensors, with these being close to the passive components but having a wide range of applications. The range of materials available for 3D printed electronics is limited compared to printed electronics. Most conductive materials are based on metals or carbon nanomaterials, although the second group exhibits several orders of magnitude higher resistivity.

**4.2.1 Electrical and electronic components.** Electronic circuits consist mostly of conductive paths, traces, electrodes, connectors, sometimes also used as resistors, antennas or coils. Due to this, most of the work is focused on the fabrication of such passive elements of the electrical and electronic circuits. By far, the greatest number of research on 3D printed electronics is in the area of electrically conductive and resistive elements, utilised with the most efficient technique FDM and the most promising nanomaterials – carbon nanomaterials. Polymer composite materials containing graphene,<sup>272–274</sup> carbon black (CB)<sup>225,275</sup> and carbon nanotubes<sup>276,277</sup> are prepared with a thermoplastic matrix in filament form (Fig. 5a). Such composites usually have fairly high resistivity, several orders of magnitude higher than metals or even metal-filled composites. Carbon-based composite filaments and printed elements prepared with the FDM technique exhibit electrical conductivity values in the range of  $10^{-3}$  S m<sup>-1</sup> to 10 S m<sup>-1</sup>, with nanomaterial loading ranging up to 10 wt%.<sup>225,272,278</sup> Such values are acceptable for the fabrication of resistors and other mentioned structures (such as sensors and EM shielding), but for high-efficiency electrical circuits, they do not perform well. Therefore other approaches are explored.

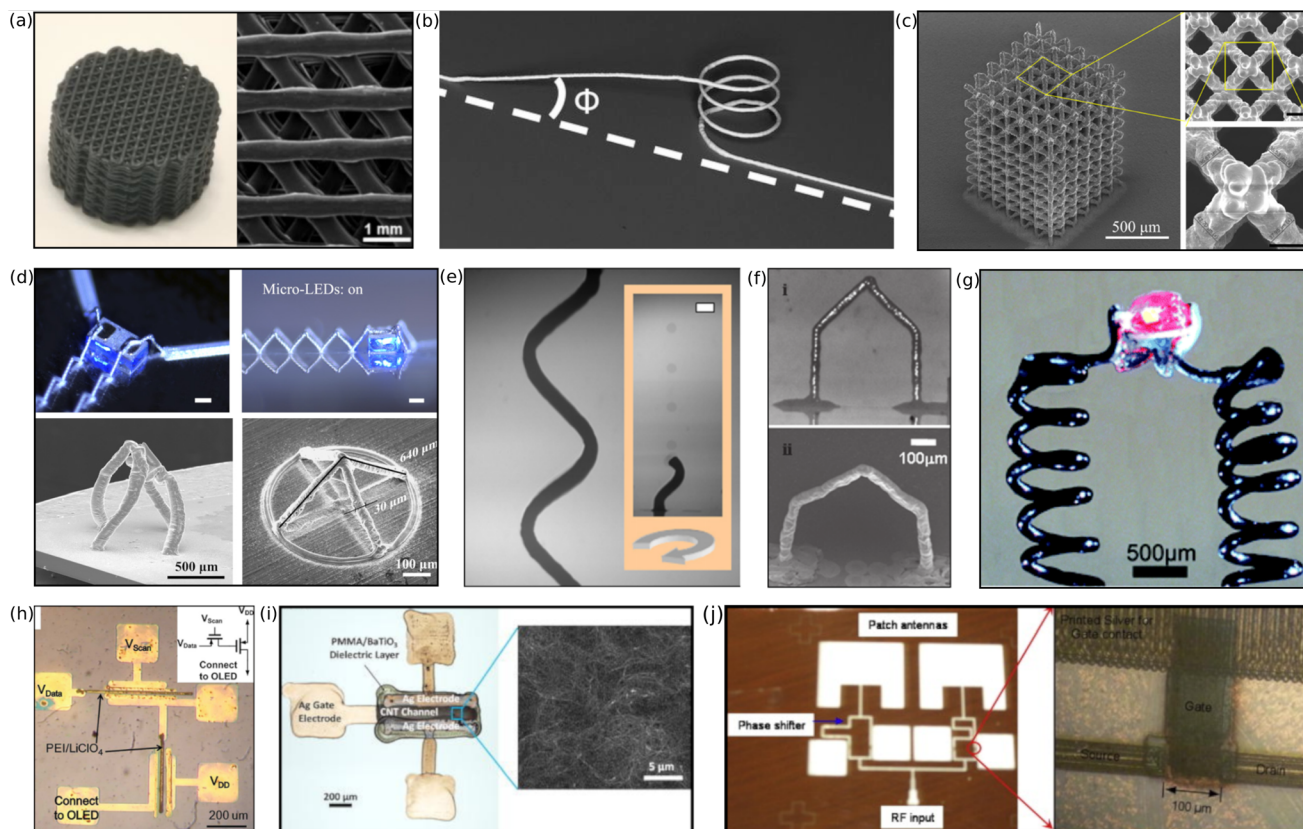
While FDM composites are high-viscosity materials with dominant polymer dielectric bases, the idea is to incorporate conductive particles in less viscous and less dense matrix vehicles. Such an approach is possible with DIW pastes and ink extrusion techniques, where much higher loadings allow for achieving much higher conductivity values. With the application of conductive pastes and carbon nanomaterials also, conductive/resistive elements can be fabricated, although

instead of thermal melting and extrusion of the composite filament, here the paste is extruded from the nozzle at room temperature and additionally cured by the evaporation of the solvent. This approach allows for the preparation of conductive compositions with GNPs or CNTs with loading as high as 40–60 wt% resulting in the conductivity values reaching up to  $10^3$  S m<sup>-1</sup> for carbon nanomaterial-based lines.<sup>41,279–282</sup> Other than heated solvent evaporation, also freeze drying is applied for 3D printing of silver NWs and graphene aerogels with combined DIW and ink-jet techniques.<sup>164,283,284</sup> But the DIW technique has more advantages, especially in the use of metal nanopowders as inks and paste conductive fillers. Similarly to the use of carbon nanomaterials, a high loading of nanoparticles can be obtained here as well, yet additional thermal sintering of the deposited paste allows obtaining almost solid metallic lines. With the use of silver NPs with loading as high as 60–80 wt%, electrical conductivity in the range of  $10^7$  S m<sup>-1</sup>, close to the values of bulk silver or copper is possible.<sup>150,285–288</sup> Although the DIW technique is often used for planar applications, with this technique it is possible to fabricate conductive 3D printed structures such as coils or grids (Fig. 5b).<sup>289</sup> With the DIW technique also, a broader range of materials can be utilised, such as MXenes. With this group of materials and the DIW technique, various microelectronic, sensing and biological inks were prepared for the fabrication of electronic structures with conductivity up to 200 S m<sup>-1</sup>.<sup>290–292</sup> Additionally, with the mixture of GNPs functionalized with Fe<sub>3</sub>O<sub>4</sub> nanoparticles, DIW printed and thermally annealed, the obtained composites exhibited conductivity of 580 S m<sup>-1</sup>, and in addition, a saturation magnetization value of 15.8 emu g<sup>-1</sup> was obtained.<sup>293</sup>

Of course, it is obligatory to mention ink-based techniques, such as AJP or ink-jet, further adaptable also Multi-Jet for 3D printing. As mentioned before, ink-based methods are often classified as 3D printing, while they actually fabricate thin layers. Only if the hybrid technique of Multi-Jet is applied the spatial elements are fabricated. Nevertheless, the applicability of the achievements of printed electronics with digital ink techniques such as ink-jet and AJP is enormous, and therefore the application of these selected ink-based techniques is intentionally presented in this review. The advantage of these techniques is the ability to incorporate metal nanopowders for further sintering processes, which is impossible for the FDM process. Also, a higher loading of carbon nanomaterials can be obtained (in the conductive layer) due to the lack of excessive polymer matrix, obligatory for the FDM process. Conductive lines prepared from metal nanoparticles, usually sintered at elevated temperatures, allow achieving with little effort resistivity close to the bulk metals.<sup>101,182,294,295</sup> At the same time, carbon nanomaterials inks allow the fabrication of electrodes with conductivity a few orders of magnitude lower (up to  $10^4$  S m<sup>-1</sup>).<sup>177,296–300</sup> Therefore more interesting approaches for the use of ink-based techniques will be listed regarding practical applications such as sensors or active components. But the ink-jet technique is also capable of fabricating multilayer, nonplanar circuits.<sup>185,301</sup> A few publications mention the preparation of various conductive 3D microstruc-







**Fig. 5** (a) FDM 3D printed porous part of LLDPE/GNPs, with the SEM image of the internal microstructure.<sup>274</sup> Reprinted with permission from Elsevier, copyright 2021. (b) Freeform 3D metallic freestanding helical silver coils with diameter = 500  $\mu\text{m}$ , fabricated with combined DIW and laser sintering.<sup>289</sup> Reprinted with permission from the National Academy of Sciences, copyright 2016. (c) AJP printed microarchitectures with elements having a diameter of about 35  $\mu\text{m}$ , and (d) stretchable spatial interconnects assembled between two micro-LEDs, also with spiral high aspect ratio hollow columns forming a dome.<sup>305</sup> Reprinted from the American Association for the Advancement of Science, under Creative Commons Attribution-NonCommercial license, copyright 2017. (e) Micro helix and (f) micro bridge interconnector microstructures of metal NPs fabricated by modified ink-jet printing.<sup>303</sup> Reprinted with permission from IOP Publishing, copyright 2010. (g) Optical image of two helical sensors DIW printed from electrically conductive PLA-MWCNT nanocomposite paste supporting and powering LEDs.<sup>313</sup> (h) Control circuit made of two fully ink-jet printed top-gated SWCNT TFTs.<sup>316</sup> Reprinted with permission from American Chemical Society, copyright 2011. (i) Fully AJP printed flexible photo-detector using SWNTs, with the SEM image of the printed SWNT network on top of PMMA/BaTiO<sub>3</sub>.<sup>320</sup> Reprinted with the permission of AIP Publishing, copyright 2017. (j) Photographs of the AJP printed SWCNT-based flexible device with printed TFTs.<sup>321</sup> Reprinted with permission from Elsevier B.V., copyright 2010.

tures (bridges, pillar arrays, helices, and zigzags) with the conductivity reaching  $10^6 \text{ S m}^{-1}$ ,<sup>302–304</sup> and the same applies to the fabrication of 3D microlattices and other structures with the AJP technique (Fig. 5c and d).<sup>305</sup>

More exotic additive manufacturing techniques incorporated for the fabrication of 3D printed electronics are SLS and SLA. For the SLS (or SLM) technique, the approach is quite similar to the fabrication of construction elements, and regular metal powders can be used to form electrically conductive metal elements. Yet, for precise micro-components, silver and copper NPs are used instead of micro powders. With such adaptation, the electrical conductivity of  $10^6 \text{ S m}^{-1}$  is reached.<sup>289</sup> With the SLS technique also, composite powders with carbon nanomaterials can be used. Sintered conductive 3D objects based on a 1 wt% CNT/TPU (flexible thermoplastic polyurethane) composite were obtained, exhibiting good flexibility and an electrical conductivity of  $0.1 \text{ S m}^{-1}$ .<sup>306</sup> For photo-

resin-based techniques such as SLA, there are no major breakthroughs in the fabrication of conductive elements. Few papers report results of the fabrication of 3D objects with *in situ* syntheses of conductive Ag NPs formed by UV irradiation of a photocurable resin and silver nitrate, with “measurable resistance” (500 k $\Omega$ )<sup>307</sup> or graphene-based compositions subjected to thermal post-treatment reaching a conductivity of  $10^{-5} \text{ S m}^{-1}$ .<sup>308</sup>

Having conductive electrodes, we are able to fabricate another passive element, a capacitor. Various research groups have demonstrated fully printed capacitors from silver and gold nanoparticle inks with the planar ink-jet technique,<sup>309,310</sup> and with graphene/carbon-based conductive filaments with FDM,<sup>311</sup> exhibiting a capacitance of  $3.1 \text{ nF cm}^{-2}$ , 314 pF and 150 pF respectively. Also, multilayered capacitors and inductors fabricated with the ink-jet technique and AgNP inks, being very close to the Multi-Jet approach for 3D printing, were



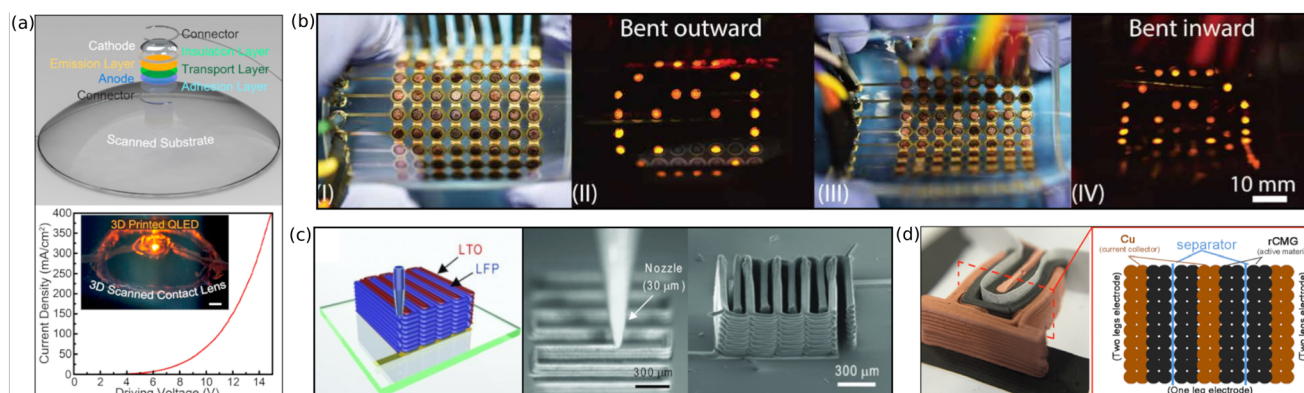
demonstrated.<sup>312</sup> A large group of supercapacitors, having gained special interest regarding the application of nanomaterials, is described in further sections.

Being able to fabricate 3D metallic structures with DIW<sup>289</sup> and ink-jet techniques<sup>302–304</sup> opens the possibility of the fabrication of other passive components – inductors and antennas for various fields ranging from smart packaging, anticounterfeiting, healthcare to public safety applications (Fig. 5e and f). But carbon nanomaterials are also used for the fabrication of such components, and here DIW and FDM techniques play an important role. Based on the experiments of printing 3D free-standing conductive structures from CNT-PLA composites, such as 3D helix (inductor) (Fig. 5g),<sup>313</sup> several attempts were made to fabricate 3D printed inductors for wireless charging application using the FDM printing technique,<sup>311</sup> or 3D printed antennas for radio frequency identification (RFID) tags.<sup>314</sup> A similar approach was also used for the fabrication of lightweight EMI shielding from 3D printed PLA/graphene nanocomposites, with reflection in the X-band frequency of 16 dB.<sup>315</sup>

On the other hand, we also need active components such as diodes and transistors, with these being the fundamental components of modern advanced electronic circuits. These components are typically multilayered and are built from different materials such as semiconductors, conductors, and dielectrics, *i.e.* channel, electrodes (drain, source, gate), and isolation dielectrics in the most simple transistor. On the mass scale, the fabrication of high-performance active components is based on silicon wafer technology. Yet, printed electronics for at least two decades has been working on the large-scale fabrication of printed diodes,<sup>14</sup> transistors,<sup>310,316</sup> and microchips (Fig. 5h).<sup>18,317,318</sup> For the 3D printed electronics, the biggest restriction is in the structure of the transistor. The main principle is based on thin layer structures, and therefore none of the truly 3D printed techniques is capable of fabricating such

fine features (in the range of  $\mu\text{m}$ ), besides ink-jet (Fig. 5i)<sup>319,320</sup> and AJP<sup>321</sup> techniques (Fig. 5j). Therefore for the fabrication of high-efficiency active circuits, the need for the integration of 3D printing techniques such as FDM, SLA or SLS with ink-based techniques well developed for printed electronics still remains. As a closing note, it is worth mentioning that the direction for the development of high-performance silicon chips in the nm technology is based on the 3D structures of the channel and surrounding gate,<sup>322,323</sup> but these structures are still fabricated with photolithography used in silicon technology, and not with additive manufacturing as described in this review.

**4.2.2 Photonic devices.** Besides electrical and electronic components listed in the previous section, which require high electrical conductivity or carrier mobility, there are also photonic devices and structures for which other requirements must be met. As mentioned previously, here also the ink-jet technique is exploited for the fabrication of precise electrodes from nanoparticle inks or transparent electrodes for a light emitting diode (LED).<sup>324</sup> But a similar structure was fabricated with the DIW technique, depositing a 5-layer LED with an emissive layer made up of a quantum-dot material on a contact lens, with light emission comparable to LEDs printed on flat substrates ( $100 \text{ cd m}^{-2}$ ) (Fig. 6a).<sup>242</sup> Also, a hybrid 3D printing approach was demonstrated for the fabrication of flexible OLEDs from printed Ag NPs and PEDOT:PSS, with AJP and DIW techniques (Fig. 6b).<sup>325</sup> A less advanced approach uses DIW techniques with graphene inks to formulate honeycomb pillar arrays as a support for discrete LEDs for the fabrication of flexible light-emitting displays.<sup>326</sup> The big potential in additive manufacturing lies in the 3D fabrication and deposition of composite luminophores and scintillators.<sup>327,328</sup> The processability of quantum dots in colloidal solutions makes them highly compatible with Multi-Jet and DIW 3D printing processes. Almost all inks mentioned in the literature with QD



**Fig. 6** (a) 3D printed QD-LED onto a curvilinear contact lens.<sup>242</sup> Reprinted with permission from American Chemical Society, copyright 2014. (b) 3D printed flexible OLED displays with the demonstration of different combinations of bending orientations.<sup>325</sup> Reprinted from the American Association for the Advancement of Science under a Creative Commons Attribution NonCommercial License 4.0, copyright 2022. (c) 3D interdigitated microbattery architecture fabricated with the DIW printing technique.<sup>336</sup> Reprinted with permission from John Wiley and Sons, copyright 2013. (d) FDM printed supercapacitor device including a cellulose paper separator and positive and negative electrodes, with a scheme of the cross section.<sup>338</sup> Reprinted with permission from American Chemical Society, copyright 2017.



nanomaterials for ink-jet printing (*i.e.* ref. 329–331) are directly applicable for the Multi-Jet 3D printing technique with minor modifications. While luminophore composites do not have to be electrically conductive, which is the major challenge for UV-cured resin composites, an adaptation of nanoparticles for SLA build optical layers and structures is promising. With the VAT polymerisation technique, several optoelectronic structures have already been prepared from titanium dioxide NPs for a tunable refractive index,<sup>332,333</sup> CdSe–ZnS fluorescent QD composites,<sup>334</sup> and 3D printed plastic scintillators for dosimetry applications in low-cost PET scanners.<sup>328</sup>

**4.2.3 Energy storage devices.** Compared to other electronic components and devices, energy devices fabricated with printing techniques are still a relatively new and emerging research field. An example of successful fabrication of a fully 3D printed free-standing lithium-ion battery with the DIW technique has been reported, with the use of graphene oxide ink for the battery electrodes and a solid-state electrolyte ink containing Al<sub>2</sub>O<sub>3</sub> nanoparticles, exhibiting capacities up to 170 mA h g<sup>−1</sup>.<sup>335</sup> The DIW approach is quite popular for the fabrication of batteries and supercapacitors, while it enables the use of various high-filled conductive and other materials, such as electrolytes. 3D fabricated microbattery architectures were printed this way from water-based lithium titanate (LTO) and lithium iron phosphate (LFP) nanoparticles, with up to 60 wt% loading of nanomaterials, to print high aspect ratio (up to 11) 3D electrodes, allowing for areal energy and power density reaching 9.7 J cm<sup>−2</sup> and 2.7 mW cm<sup>−2</sup>, respectively (Fig. 6c).<sup>336</sup> Also, graphene aerogels were used in the fabrication of combined DIW and ink-jet electrodes to formulate electrodes with periodic macropores enabling the fabrication of supercapacitors with parameters superior to other carbon-based electrodes (from 0.5 to 10 A g<sup>−1</sup>), demonstrated by powering a red LED for 3 min, a digital timer for 5 min, and a small electric fan for several seconds.<sup>337</sup> Many similar approaches can be found in the literature, which mention the use of graphene and copper-containing thermo-responsive inks in fabricating electrodes, additionally sintered, for electrochemical batteries (Fig. 6d),<sup>338</sup> nanoporous graphene-based cathodes for Li–O<sub>2</sub> batteries,<sup>339</sup> CNT-based electrodes for microsupercapacitors<sup>340</sup> or 3D printed hybrid molybdenum disulfide (MoS<sub>2</sub>)–graphene aerogels to fabricate porous electrodes for sodium-ion batteries.<sup>341</sup> Speaking of porous electrodes and ink-based techniques, it is worth mentioning a rare use of the AJP printing technique to fabricate actual 3D structures in the form of porous microlattices of silver nanoparticles as electrode materials for lithium-ion batteries.<sup>342</sup> AJP was also successfully utilised for the fabrication of active layers<sup>343</sup> and current collecting grid electrodes<sup>344,345</sup> in solar cells. Also, MXenes found their application in the fabrication of freestanding electrodes for supercapacitors printed with DIW and ink-jet techniques.<sup>346,347</sup>

Other techniques and applications cover, for instance, the preparation of graphene-based PLA composite filaments for the FDM technique to fabricate electrodes for pseudo-capacitors<sup>348</sup> or submicron graphite PLA composites for printing

electrodes to investigate the electrochemical performances of such 3D printed materials.<sup>349</sup> Also the SLA technique was utilised to print capacitors from polymer composites containing silver NP decorated lead zirconate titanate powders (PZT), with the observable negative influence of Ag nanoparticles increasing the refractive index and thus decreasing the cure depth of the resin.<sup>350</sup>

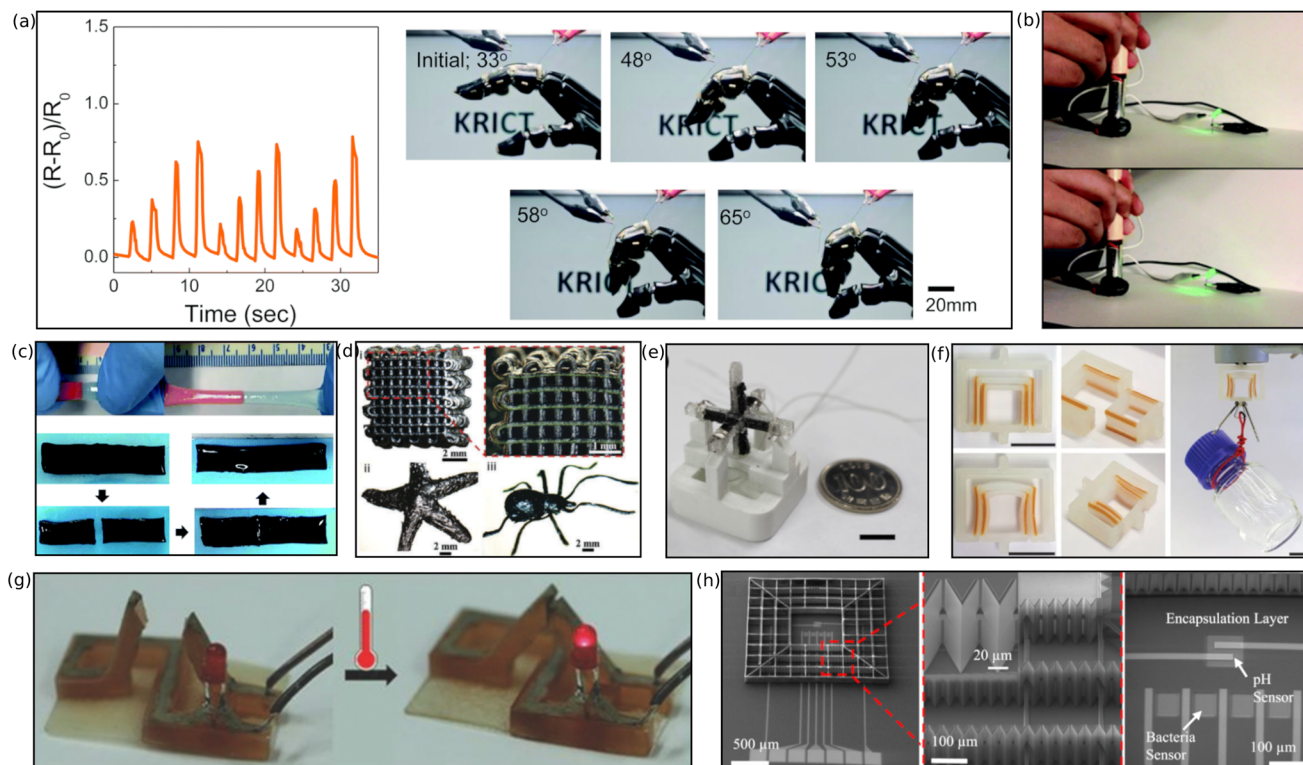
**4.2.4 Sensors.** One of the most broadly explored areas of research in 2D and 3D printed electronics is sensor applications. This is due to the possibility to easily adapt to basic conductive and resistive electrodes as a strain, temperature, electrochemical and other basic types of sensors. Here we are also covering the attempts described in the literature on similar applications, having in mind elements fabricated additively in 3D geometrical shapes or embedded inside 3D structures, leaving aside printed sensors on flat, elastic substrates dominant in printed electronics.

DIW and FDM techniques play a major role in the fabrication of 3D printed sensors. Most often, carbon nanomaterials are used as functional fillers in inks and composites. One of the examples is a strain sensor from graphene–PDMS paste, printed in multiple directions to fabricate a sensor mesh,<sup>351</sup> which is further modified with silica nanoparticles to enhance the mechanical and thermal properties.<sup>352</sup> Several similar approaches utilising GNPs or CNTs can be found in the literature, as the preparation of carbon nanomaterial-based slurries for DIW printing is one of the simplest approaches for applying these nanomaterials for 3D printed sensors,<sup>353,354</sup> (Fig. 7a and b) also with the use of food-inspired egg white as an organic hydrogel (Fig. 7c).<sup>355</sup> One of the most impressive attempts to 3D print such structures with water-driven self-healable MWCNT–chitosan compositions for DIW is presented in the form of multilayered scaffolds, spider- and starfish-shaped objects (Fig. 7d).<sup>356</sup> But besides carbon nanomaterials also, silver NWs and cellulose nanocrystals were adapted for ion detection in wireless sensor systems.<sup>357</sup> The same applies to a mixture of cellulose nanofibers with MXenes for printing self-healable strain sensors, although printed with various shapes as one layer only, such a technique holds great potential for 3D printing.<sup>290</sup> Of course, the variety of ink-based printing techniques applied for sensor fabrication is much wider, including AJP sensors from graphene for immunosensing<sup>358</sup> or silver NP based for cerebral aneurysm monitoring<sup>359</sup> but low viscosity ink techniques still have a long way for the fabrication of truly 3D printed elements.

Great potential also lies in the FDM technique and nanocomposites for the fabrication of sensors, as they do not have to exhibit exceptionally high conductivities and because the FDM technique is one of the most suitable techniques for the fabrication of bulk structures with embedded sensors. One of the most often described materials in the literature for FDM printing of sensors are CNT, GNP or other carbon-based composites with PLA and ABS. Commercial materials “carbo-morph” and “blackmagic” are among the most often used materials for FDM fabrication of electronics.<sup>225,348,360,361</sup> The electrical, thermal and mechanical properties of 3D printed







**Fig. 7** (a) DIW printed nanotube and graphene composite strain sensors for detecting robot finger motions with different bending angles.<sup>353</sup> (b) 3D printed graphene-based hydrogel sensor demonstrating strain-dependent conductivity.<sup>354</sup> (c) DIW 3D printed stretchable hydrogel from natural egg white for fabrication of electronic sensors and actuators, demonstrating a self-healing capability without any external stimulus.<sup>355</sup> (d) Chitosan–CNT solvent composites for sensors, demonstrating 3D printed scaffolds as spider and starfish-shaped structures.<sup>356</sup> (e) 3D cubic cross multiaxial force sensor on a FDM printed structure fabricated with CNT–TPU filaments.<sup>276</sup> Reprinted with permission from Elsevier, copyright 2017. (f) Magnetically assisted 3D printed composite actuators.<sup>376</sup> Reprinted from Springer Nature, under Creative Commons CC BY license, copyright 2015. (g) 3D printed shape memory-based electrical devices from carbon nanotubes with a temperature activated sensor in its “off” and “on” state.<sup>380</sup> Reprinted with permission from John Wiley and Sons, copyright 2016. (h) A bio-inspired 3D printed graphene-based micro-structure for sensing of bacteria.<sup>388</sup> Reprinted from Elsevier B.V., under Creative Commons CC-BY license, copyright 2019.

MWCNT/ABS were also examined with respect to the influence of printing parameters, here the deposition direction, on the mechanical and electrical properties of composite sensors.<sup>362</sup> Biomedical sensing systems play an important role in the studies on FDM printed composites with PLA and carbon nanomaterials due to the biocompatibility of such materials.<sup>362</sup> A simple cone-geometry electrode printed from a carbon–PLA composite has been used in an *ex vivo* experiment over the gut tissue of guinea pig for monitoring the serotonin level and muscle contraction.<sup>363</sup> Other approaches include PLA/graphene electrodes for the detection of  $\text{H}_2\text{O}_2$ ,<sup>364</sup> a mycotoxin (ZEA) compound,<sup>365</sup> metal ions in biological specimens,<sup>366</sup> glucose biosensing,<sup>367</sup> and immunobiosensors for the detection of viruses.<sup>368</sup> Using a similar material, a graphene–ABS composite, a 3D printed electrocardiogram (ECG) sensor was FDM printed and additionally coated with titanium and a gold layer to prevent corrosion and oxidation.<sup>369</sup> Substituting the rigid ABS or PLA matrix with a flexible thermoplastic polyurethane matrix filled with MWCNTs allows for the fabrication of elastic strain sensors using the piezoresistive changes in materials properties.<sup>370</sup> Also, MXene and CNT

reinforced TPU composites were implemented for elastic strain sensors and electromagnetic shielding applications (Fig. 7e).<sup>276,371</sup> Other nanomaterials can also be incorporated into the FDM polymer composites, such as ABS filled with magnetite nanoparticles ( $\text{Fe}_3\text{O}_4$  NP) for the fabrication of glucose sensors,<sup>372</sup> or immobilised on the surface of printed PLA/graphene electrochemical sensors, as presented for electrodes modified with gold nanoparticles (Au NPs) in the literature.<sup>373</sup>

Only a few examples present the utilisation of the SLA technique for fabricating composite sensors due to the obstacle in the preparation of conductive structures with VAT polymerisation materials. In one of the publications, work towards the integration of mechanical and electrical properties in complex 3D shapes is presented, which used graphene nanoplatelets aligned with an electric field during SLA printing for a 3D printed lightweight smart armour that can sense its damage with a hesitated resistance change.<sup>374</sup> Also, a strain sensor array was fabricated from a UV curable resin with MWCNTs, with additional responses to humidity and temperature.<sup>375</sup>



**4.2.5 Microelectromechanical systems.** Spatial variations in the distribution and orientation of nanomaterials can impact the shape-changing abilities in 3D printed architectures, opening the possibility of fabricating 3D printed actuators. Orienting nanofibers and platelets can produce shape-changing structures with programmable shape deformations, as presented in the approach for DIW with alumina platelets (Fig. 7f).<sup>376</sup> This much simpler approach relies on the most basic working principle of actuators – thermal stress induced by electrical current. A soft flexible actuator was fabricated on that basis using DIW of a GO ink, acting as a sensor and exhibiting bending with the connected voltage.<sup>42</sup> A similar approach with a DIW printed ionogel was used for the fabrication of soft actuators with haptic, proprioceptive, and thermoceptive sensing.<sup>377</sup> Other results demonstrate DIW 3D printed cellulose nanocrystal composite architectures inspired by nature with a high degree of cellulose NC particle alignment, inducing programmable reinforcement along the prescribed directions that exhibit tailored responses to the applied mechanical load.<sup>378</sup> Several groups have tackled the VAT polymerisation approach. For example, ferromagnetic iron nanoparticles confined by an applied magnetic field within an SLA printed structure exhibited regional differences in magnetic remanence, useful for teleoperation, rotation, translation, and deformation.<sup>379</sup> A similar approach to SLA printing was used to fabricate an actuator triggered by temperature, demonstrating a simple on–off switch for electrical circuits (Fig. 7g).<sup>380</sup> With the use of two-photon polymerization, a magnetic polymer composite with Fe<sub>3</sub>O<sub>4</sub> nanoparticles was used to fabricate an actuator for swimming microrobots.<sup>381</sup>

Being able to print micromechanical fine structures and integrate them with electronic circuits end elements sparked the idea for the fabrication of lab-on-chip microsystems. Lab on a chip is defined as research towards miniaturizing biological or chemical processes, with input from microfluidics and miniaturized sensors (biochips), typically utilising time-consuming, multi-step lithographic processes to fabricate such MEMS systems.<sup>382</sup> Here 3D printing emerged allowing for rapid customization and new applications with 3D structural electronics. An entirely DIW-printed lab on a chip consisted of carbon–TPU printed strain gauges, followed by electrical leads and contact pads printed with silver-nanoparticle polyamide ink and various insulating and support layers. This biochip micro-architecture allowed growth and monitoring of cardiac tissues over the course of a month.<sup>383</sup> Also, a nanoparticle luminescent indicator ink was used with the DIW technique to print sensors integrated into scaffolds for the growth and metabolic activity monitoring of microalgae and mesenchymal stem cells.<sup>384</sup> The micro-fluidics and micro-drive applications of the FDM technique include configurable 3D printed microfluidic lab on a chip reactionware devices for chemical syntheses, fabricated in just a few hours, used for gold nanoparticle synthesis.<sup>385</sup> Furthermore, module-based microfluidic components were fabricated from polymers with FDM and integrated nano-/micro-particles as biosensors to detect the AFP antigen.<sup>386</sup> An SLA printed microfluidic device with magnetic

nanoparticles was used to actively remove and sort *E. coli* bacteria from a solution.<sup>387</sup> A similar VAT technique, two-photon polymerization (2PP), was used to create a bio-inspired microscopic cage for motile bacteria to improve the sensitivity of a graphene-based biosensor (Fig. 7h).<sup>388</sup>

## 5 Perspectives

It is worth noting that during the preparation of this review, many new techniques and applications emerged or are under development and hence, they are not mentioned here. Secondly, only the most popular 3D printing techniques were taken into account, and tens or hundreds of other techniques and modifications exist that can also be applied for the fabrication of 3D printed electronics, just to name a few exotic ones such as fluid shear patterning, evaporative patterning, acoustic patterning, electrical patterning, magnetic patterning, optical patterning, thermal patterning *etc.*<sup>181</sup> One of the most obvious areas of advancement lies in the implementation of ink-based techniques such as ink-jet and AJP for the fabrication of truly 3D structures, as presented previously for the rare application of AJP for fabrication of microlattices.<sup>305,342</sup> The development of new materials is also progressing by visibly approaching MXenes for the fabrication of conductive and radio-frequency devices.<sup>389,390</sup> Also, new forms of materials allow resolving some previously mentioned problems with the application of various nanomaterials, for instance, silver-coated copper nanopowder core-shell particles (CuNP@Ag),<sup>391</sup> or Ni coated<sup>392</sup> or Sn coated particles,<sup>30</sup> for limitation or elimination of the reactivity of Cu NPs. This section covers also the area of interdisciplinary approaches combining commonly separated fields of research *i.e.* electronics and biomedicine.

The broad area for development covers the preparation of a whole new branch of materials for VAT and Multi-Jet techniques, using both UV curable resins. Due to the mentioned restrictions related to the fabrication of highly conductive UV-cured composites, only dielectric, photonic, magnetic or highly resistive materials can be obtained, severely limiting the application of these techniques. Already many problems with the adaptation of VAT techniques for 3D printed electronics are observed, such as the negative impact on the polymerisation process with a high concentration of metal or ceramic and oxide nanoparticles,<sup>332,333,393</sup> forcing additional sintering procedures to obtain conductive structures with silver NPs for ink-based techniques.<sup>394,395</sup>

Unfortunately, for VAT polymerisation and powder-bed techniques, there is a more fundamental restriction: one material at a time. While most of the extrusion or ink-based techniques, such as FDM or Multi-Jet, are easily adaptable for multi-material printing, it is extremely difficult for SLA and SLS techniques. This limitation is often solved by separate printing and attaching layers with different properties and materials,<sup>396,397</sup> or by the replacement of resins or powders, leading to the repetition of the process.<sup>398–402</sup> Such an approach significantly slows down the process, increases the overall manufacturing



time, and poses the risk of cross-contamination between materials, which becomes even more apparent taking into account that frequent material change is needed for hundreds of layers with the increasing complexity of the part. Only the recent example of the VAT polymerisation technique deals with this problem, utilising a dynamic fluid control and exchange process, enabling a fast switch between liquid photopolymers, even including micro-/nano-particle suspensions. Such a technique was even used for the fabrication of actuators based on UV resins filled with Cu and Al<sub>2</sub>O<sub>3</sub> nanopowder.<sup>403</sup>

In the scope of multi-material printing, the most frequent approach is introducing hybrid techniques, being a partial solution for the limitations of UV-cured VAT techniques and powder-bed ones. Already one of the most popular adaptations of the SLA technique for the fabrication of electronics is 3D printing of substrates, even 3D shaped, and filling specially prepared grooves with conductive inks, most often with DIW, ink-jet or AJP techniques.<sup>229–231,404</sup> The same applies for the FDM or SLS printed substrates even for the fabrication of active components such as transistors.<sup>405</sup> Additional laser sintering of metal NPs can be applied.<sup>288,406</sup> While the binder-jet technique already uses ink-jet printing, the materials in one section of printing heads can be replaced with conductive inks or the AJP technique can be incorporated into the process.<sup>132</sup>

As we saw previously in the section regarding 3D printing of biomedical sensors or lab-on-chips and in the large section of 3D printed electronics, the most obvious next step is the combination of both of them. One aspect is the enhancement of functionality in both electronic systems and biomedical applications. The second one is related to the biocompatibility of carbon-based nanomaterials, which can additionally foster the development of 3D printed bioelectronics. Nanomaterials as additives are already used in 3D printed biocompatible substrates such as hydrogels to enhance bioactivity and cell viability. The seamlessly interweaved electronics with geometrically complex, biocompatible scaffolds and devices can additionally enhance already complex biological systems.<sup>407–411</sup> A more advanced approach covers the use of FDM or DIW techniques and carbon nanomaterials in the fabrication of electrically conductive scaffolds for effective stimulation of cell proliferation for implants and biological tissues or organs.<sup>41,383</sup> One of the most impressive achievements covers the use of DIW printing of a regenerative scaffold with living chondrocytes in the shape of an ear and co-printed with silver nanoparticles as a coiled antenna inside the ear, which is the most visible example of the possibility of integrating biological constructs with functional electronics.<sup>412</sup> This topic is not entirely new, and readers can refer to several review papers covering 3D printed biodevices.<sup>413,414</sup>

4D is another approach. It has already been briefly mentioned with 3D printed actuators. With additive manufacturing, 3D printed origami electronics, self-assembling conductive structures, and bioinspired shape-changing systems are also fabricated.<sup>399,415–418</sup> Finally, embedding interconnects is the topic for future works on 3D printed electronics for the integration of SMD-components<sup>419</sup> followed by the effective

design of 3D circuitry, including also toolpath planning and alignment of the 3D parts for optimal printing.<sup>420</sup>

The areas for exploration of 3D printed structural electronics with nanomaterials are vast and could also dig deeper into surface activation and growth of nanoparticles on 3D printed structures, selective electrochemical metallization of low conductivity carbon composites and SLA structures, especially important for high-frequency radio circuits or electromagnetic interference shielding. All breakthroughs and successes in the 3D printing of electronics mentioned in this paper allow reimagining our approach for fabricating electronics. However, many challenges remain for the application of nanomaterials for the 3D printing of electronics, and more efforts need to be made for this technology to be widely adopted in mass production by the electronic manufacturing industry.

## Author contributions

M. S. investigated the literature, wrote the original draft, assembled the figures and revised the manuscript.

## Conflicts of interest

There are no conflicts to declare.

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